# Fabrication of polymer-based devices using nanoimprint technology

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Polymer material is emerging as an important alternative to conventional silica material in fabrication of photonics devices. As the cost of the material is low, the prices of the photonic components could be lowered down to meet economic criteria. Another advantage of polymer material is easy and rapid processibility. Film making can be much easier and more rapid by spin-coating. New advanced technology, like soft lithography and nanoimprint, simplify the waveguide fabrication process with high yield.

In this work, we introduce a novel inorganic-organic hybrid polymer PSQ-L synthesized by our partner group. This kind of polymer shows excellent optical properties and high thermal stability. Because of no solvents involved in the film making process, this pure liquid polymer is compatible with hard mold imprint technology. To test the compatibility of the material with fabrication, a grating with a width of 400nm/400nm on quartz substrate was first fabricated using nanoimprint technology. Using this polymer to fabricate all-polymer based waveguides is being investigated.

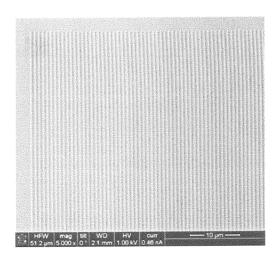
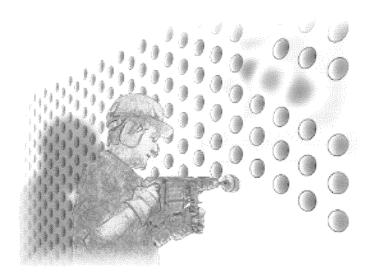


Figure 1: polymer grating with width of 400nm/400nm fabricated by nanoimprint technology



PORTOFERRAIO, ELBA ISLAND, ITALY
11 TO 17 MAY 2008





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#### ABSTRACTS OF POSTERS

### Poster session I:



- 1. V-Groove approach for inverted taper coupling in silicon photonics: J. V. Galán
- 2. Experimental Study of the Non-Linear Dynamics of Quantum-Dot InAs/InGaAsP/InP (100) Twin-Stripe Lasers Emitting at 1.5µm: Jose Pozo
- 3. InGaAs-InAlGaAs Monolithically Integrated Temporal Phase Coded OCDMA Encoder/Decoder: S. McMaster
- 4. A spectrally resolved study of quantum dot lasers: G.A.P. Thé
- 5. Carrier Transport Effects in Multi Layer Quantum Dot Lasers: M. Rossetti
- 6. Membrane couplers for optical interconnections on CMOS ICs: A. Morant
- 7. Optical Losses in Photonic Crystal Waveguides, Induced by Contact Strips for Electrical Pumping: Peter Kaspar
- 8. Measuring the Time-of-Flight with an optical MEMS-modulator: Joris Roels
  - InP-membrane based photodetector for optical interconnections on Si: P.R.A. Binetti
  - 10. High bandwidth InP-based 1.55 μm waveguide photodetector fabricated in an amplifier layer stack with active-passive integration: L. Xu
  - 11. Design and simulation of movable micromirrors on silicon substrate: Comanescu Florin Constantin
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  - 13. Liquid crystal technology for wavelength tuning in SOI structures: Wout De Cort
    - 14. Photonic Reservoir Computing: interconnected Semiconductor Optical Amplifiers: Kristof Vandoorne
    - 15. **Waveguide grating photonic system analysis for sensor applications**: Roxana Ileana Rebigan
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    - 17. Combined Technologies: Photolithography and Electron Beam Lithography for RF Filters on GaN Development: Herghelegiu Alexandru
    - 18. Deep dry-etched single-mode narrow waveguide for all-optical switches with InGaAs/AlAsSb quantum wells: Ping Ma
    - 19. Assessment of mesh-interconnected integrated photonic switch circuits: Aaron Albores Mejia
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    - 21. Adjustment of birefringence on Silicon-on-Insulator (SOI) by mechanical bending: Georg Winzer
    - 22. Analysis of thermal crosstalk between DFB-laserdiodes on SOI: B. Wohlfeil
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    - 24. Bragg Gratings on SOI Rib Waveguides A Comparison of Different Geometries: Ivano Giuntoni
    - 25. Slow Light in Chalcogenide Photonic Crystals: Marcel Spurny

#### Poster session II:

- 26. A comparative study of compact electro-optic modulators based on 1D corrugated waveguide surrounded by Silicon dioxide: Antoine Brimont
- 27. Design and Fabrication of Apodised Crows on Silicon Nitride: J.D. Domenech
- 28. Silicon optical modulator: Fengqiao Dong
- 29. Large Integration Scale Circuits in SiON Technology: Carlo Ferrari
- 30. SOI photonic wires-based devices: sidewall roughness-induced losses and characterization: Antonio Canciamilla
- 31. InP Photonic Crystals bonded to SOI wires: Yacine Halioua & Tim Karle
- 32. Fabrication of photonic integrated circuits using high resolution CMOS fabrication process: Shankar Kumar Selvaraja
- 33. Silicon compatible laser based on colloidal quantum dots: Bram De Geyter
- 34. Al2O3:Er waveguide amplifiers for Si-technology compatible integrated optical applications: L. Agazzi
- 35. Label-free nanophotonic biosensors in silicon based on slot waveguides: Tom Claes
- 36. Design of an integrated electo-optically tunable filter for tunable laser purposes: B.W. Tilma
- 37. Sol-Gel Ormosil-on-Silicon Microphotonics: Paulo Moreira
- 38. 10 Gb/s All-Optical Non-Inverted 1x4 Multi-Wavelength Conversion in a 1.55 μm QD-SOA: J. Herrera
- 39. Photonic Crystal Membrane Type Tunable Nanocavities in InP/InGaAsP: Mehmet Ali Dundar
- 40. Process Development for passive photonic circuits on BCB- bonded InP membranes on silicon: F. Bordas
  - 41. Novel grating structures for dual-mode laser devices: S. Ginestar
  - 42. Hybrid III-V/Silicon laser based on DVS-BCB die-to-wafer bonding: Stevan Stankovic
  - 43. Fabrication of high brilliance diode lasers in the near-infrared wavelength range: D. Feise
  - 44. The Nanostructuring Platform for Photonic Integration: William Whelan Curtin
  - 45. Design of a reconfigurable optical interconnect for large-scale multiprocessor networks: Iñigo Artundo
  - 46. Photonic crystal waveguides with ring-shaped holes on silicon-on-insulator: A. Säynätjoki
  - 47. Towards optimizing photonic crystal cavities for Quantum Dot coupling: Khaled Mnaymneh
  - 48. Quantum Confined Stark Effect (QCSE) Tuned Lasers: Francesca Pozzi
  - 49. Multi-waveguide based collector array for the detection of backscattered light from highly scattering media: N. Ismail
  - 50. Continuous wave InGaAsP/InP Fabry-Perot lasers on silicon: Tiphaine Dupont